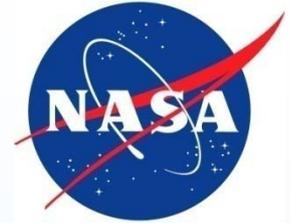


**NEPP Electronic Technology
Workshop 2012**

National Aeronautics
and Space Administration



Recent Power Metal-Oxide- Semiconductor Field-Effect Transistor (MOSFET) Test Results

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NASA Goddard Space Flight Center
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 - Ken LaBel, Ray Ladbury, Hak Kim, Anthony Phan, Megan Casey, Alyson Topper, Stephen Cox, and Tim Irwin
- **NASA/JPL**

Industry:

- **Aeroflex**
- **Fuji**
- **International Rectifier**
- **Infineon Technologies**
- **Microsemi**
- **SEMICOA**
- **STMicro**
- **Texas Instruments**
- **Tower JAZZ**
- **Vishay Siliconix**



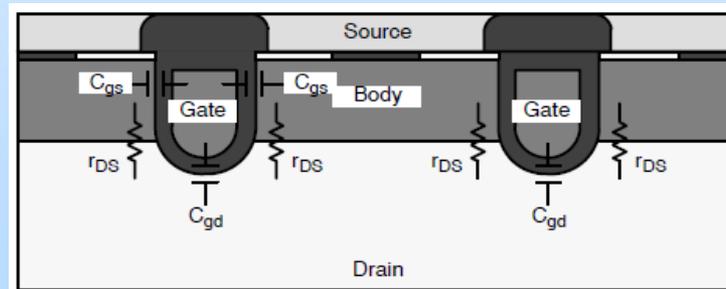
Introduction

- **NEPP focus: Evaluate alternative power devices for space applications**
 - New technologies
 - New suppliers
- **This talk:**
 - Silicon power MOSFETs – part 1 (GSFC)
- **Other talks during this NEPP ETW:**
 - Silicon – part 2 (JPL)
 - Gallium Nitride
 - Silicon Carbide

Vishay Commercial n-Type TrenchFET[®]



- Previous tests of Vishay commercial p-channel 12 V and 200 V TrenchFETs[®] showed good total ionizing dose (TID) and single-event effect (SEE) performance
 - Data presented at 2011 NEPP ETW
- **SUM45N25:**
 - commercial 250 V, 45 A, 0.058 Ω TrenchFET[®]
 - 175 °C junction temperature capability
 - ± 30 V gate rating

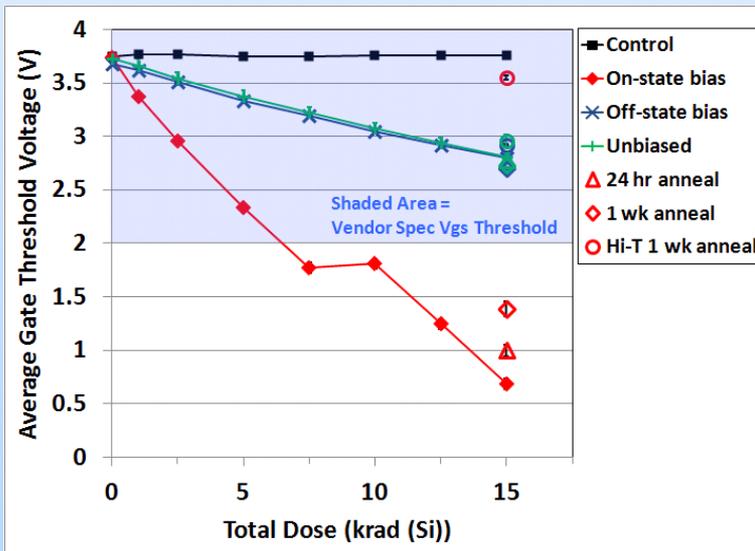


Example TrenchFET[®] cross section.
(From: Vishay Siliconix AN605)

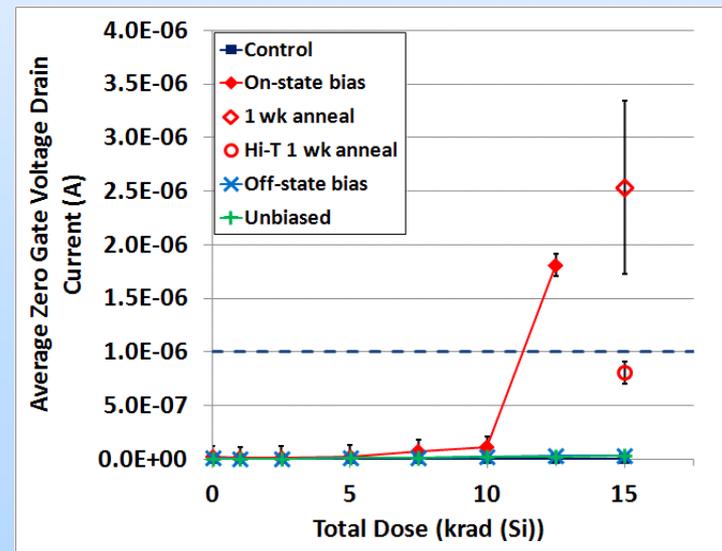
Vishay SUM45N25 Commercial n-Type TrenchFET® TID Results



- **Bias conditions:**
 - On-state: gate-source voltage (V_{gs}) = 18V; drain-source voltage (V_{ds}) = 0V
 - Off-state: V_{ds} = 190V; V_{gs} = 0V
 - Unbiased: V_{ds} = V_{gs} = 0V
- **Dose rate:** 517 rad(Si)/min, with 2.62 rad(Si)/min overnight dose from 7.5 krad(Si) to 10 krad(Si) total dose steps



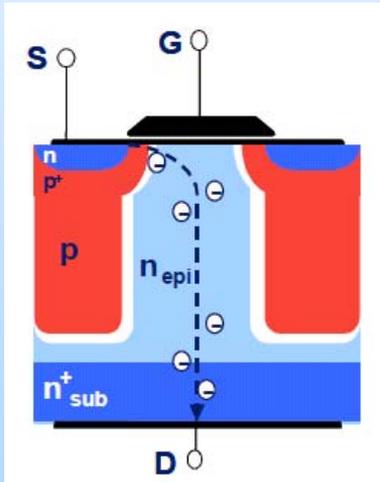
Gate Threshold Voltage



Drain Current at 0 Vgs

Infineon Radiation-Hardened n-Type Superjunction (SJ) MOSFET

- Infineon Technologies is first to develop a radiation-hardened version of a superjunction power MOSFET
 - Superjunction process should prove SEE-hardened:
 - Fields develop fairly evenly both laterally and vertically, reducing the peak field strength, thus impact ionization important for single-event burnout (SEB)
 - Reduced field strength + lateral fields reduce peak transient E_{ox} following an ion strike, important for single-event gate rupture (SEGR)



Device tested: BUY25CS54A

- 250 V, 54 A, 0.030 Ω
- 100 krad(Si) rating

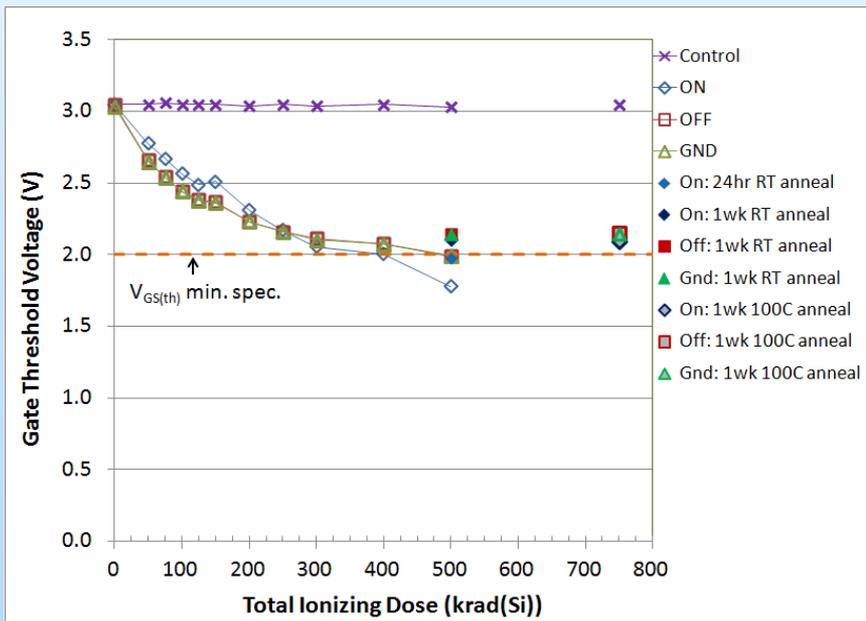
Example superjunction MOSFET cross section.

(Infineon Technologies Application Note AN-CoolMOS-CP-01)

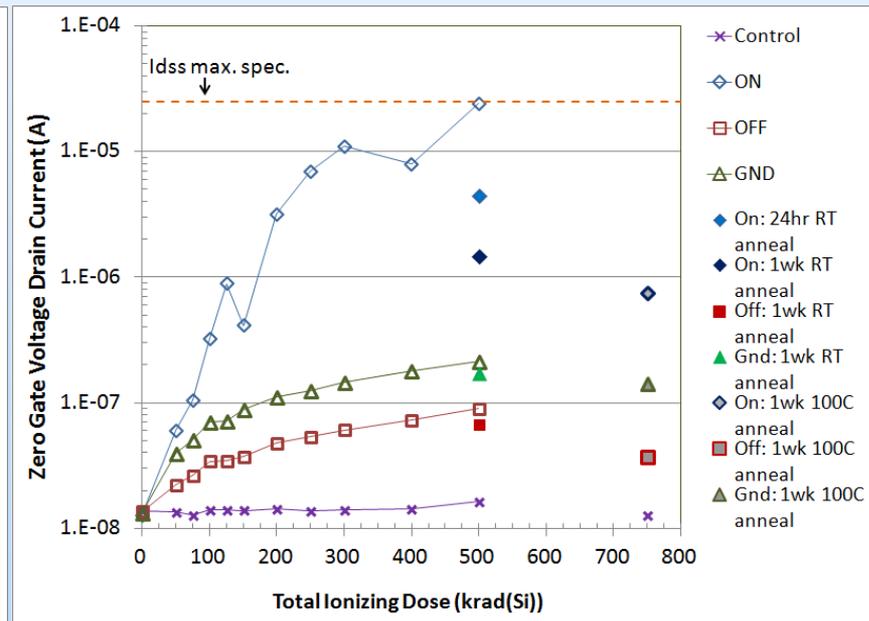
Infineon BUY25CS54A n-Type SJ MOSFET TID Results



- **Bias conditions:**
 - On-state: $V_{gs} = 12V$; $V_{ds} = 0V$
 - Off-state: $V_{ds} = 200V$; $V_{gs} = 0V$
 - Unbiased: $V_{ds} = V_{gs} = 0V$
- **Dose rate:** 940 rad(Si)/min with lower overnight rates



Gate Threshold Voltage



Drain Current at 0 Vgs



SEE Tests

- **Planned this summer:**
 - Infineon 250 V SJ MOSFET (BUY25CS54A)
 - Aeroflex 250 V vertical MOSFET (VDMOS) (RAD7264)
 - Fuji 500 V VDMOS (JAXA-R-2SK4188)
 - SEMICOA -100 V p-type VDMOS (2N7425)
 - Vishay 250 V trenchFET® (SUM45N25)
 - Tower JAZZ 40 V lateral MOSFET (LDMOS) (test chip)

Stay tuned for these and more test results!